



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :
Sang-Jun Choi : Group Art Unit: 1752
Serial No.: 09/715,041 : Examiner: Yvette C. Thornton
Filed: November 20, 2000 :

PHOTORESISTIVE POLYMER HAVING CYCLIC BACKBONE AND
RESIST COMPOSITION CONTAINING THE SAME

**AMENDMENT AND REQUEST FOR
RECONSIDERATION**

U.S. Patent and Trademark Office
Customer Window, Mail Stop Amendment
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

In response to the Office Action dated September 20, 2004, the
Applicants submit the following remarks and arguments regarding the above-
identified application as follows:

Amendments to the Claims are reflected in the listing of claims which
begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.